

Fluorination of trimethylsilylfluoro- and trimethylsilyltetrafluorobenzenes with xenon difluoride

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Abstract

Replacement of hydrogen or trimethylsilyl group by fluorine and the addition of two fluorine atoms to the aromatic ring were found in the reaction of XeF₂ with 1-trimethylsilyl-2,3,4,5- or 2,3,4,6-tetrafluorobenzenes in CH₂Cl₂ under BF₃·OEt₂ catalysis. Only addition of two fluorine atoms took place in the case of 1-trimethylsilyl-2,3,5,6-tetrafluorobenzene. The isomeric trimethylsilylfluorobenzenes underwent fluorodesilylation, fluorodeprotonation and protodesilylation. The assumed reaction pathways include both cation radicals and arylxenon(II) species as reactive intermediates. © 1998 Elsevier Science S.A. All rights reserved.

Keywords: Trimethylsilylfluorobenzenes; Trimethylsilyltetrafluorobenzenes; Xenon difluoride; Fluorination

1. Introduction

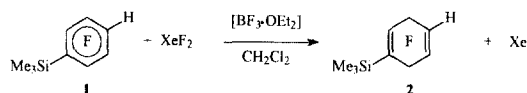
In 1993, we described the reaction of silyl- and germlyl-pentafluorobenzenes C₆F₅MX₃ (M = Si, Ge; X = F, Cl, Br, Alk) with xenon difluoride in the presence of Lewis acids [1]. When MX₃ was SiMe₃, SiMe₂C₆F₅ and SiMe₂F, the BF₃·OEt₂-catalyzed reactions proceeded smoothly at room temperature to give 1-MX₃-heptafluoro-1,4-cyclohexadienes and traces (1–2%) of hexafluorobenzene. Recently we found that tetrafluorobenzenes C₆HF₄R (R = F, Cl, Br, H, CF₃, NO₂) add two fluorine atoms or undergo fluorodeprotonation to yield the corresponding pentafluorobenzene derivatives, C₆F₅R, under the action of XeF₂ in either anhydrous HF or CH₂Cl₂–BF₃·OEt₂ (catalyst) [2]. In continuation of our systematic investigations in that field, the reaction of XeF₂ with partially fluorinated aryltrimethylsilanes has now been studied under the catalysis of Lewis acid.

In general, the introduction of one or more fluorine atoms into a molecule is described ‘fluorination’ independently of the reaction type. To be more informative these reactions should be named fluorodeprotonation, fluorodesilylation, fluorodecarboxylation, etc. (replacement of hydrogen atom, silyl, carboxy or the other group by fluorine), oxidative fluorination (attachment of fluorine atom(s) with increase of the co-ordination number of the central atom) and fluoridation (nucleophilic substitution of an atom or a functional group

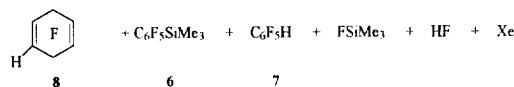
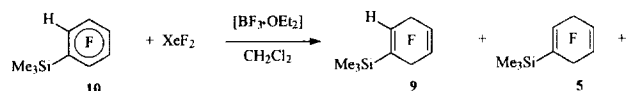
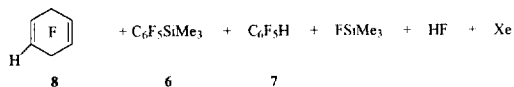
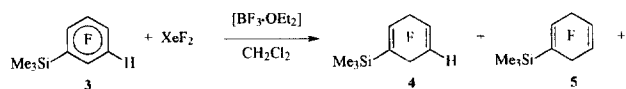
by fluoride anion). Fluorine addition (addition of two or four fluorine atoms to the multiple carbon–carbon, carbon–element or element–element bond) and fluorohalogenation, fluoroprotonation, fluoromercuration, etc. (addition of fluorine and halogen, fluorine and mercury, and related processes) are subgroups of oxidative fluorination.

2. Results and discussion

1-Trimethylsilyl-2,3,5,6-tetrafluorobenzene **1** dissolved in CH₂Cl₂ reacted with XeF₂ in the presence of BF₃·OEt₂ to give 1-trimethylsilyl-4-*H*-hexafluoro-1,4-cyclohexadiene **2** in 89% yield. However, the analogous reaction of XeF₂ with 1-trimethylsilyl-2,3,4,6-tetrafluorobenzene **3** led to a variety of products: 1-trimethylsilyl-5-*H*-hexafluoro-1,4-cyclohexadiene **4**, 1-trimethylsilylheptafluoro-1,4-cyclohexadiene **5**, trimethylsilylpentafluorobenzene **6**, pentafluorobenzene **7** and 1-*H*-heptafluoro-1,4-cyclohexadiene **8** together with fluorotrimethylsilane and HF. In a similar manner, compounds **5**, **6**, **7**, **8**, FSiMe₃, HF and 1-trimethylsilyl-2-*H*-hexafluoro-1,4-cyclohexadiene **9** were produced from 1-trimethylsilyl-2,3,4,5-tetrafluorobenzene **10** and xenon difluoride under the BF₃·OEt₂ catalysis.



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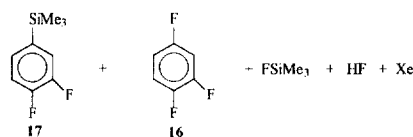
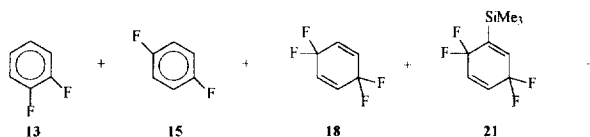
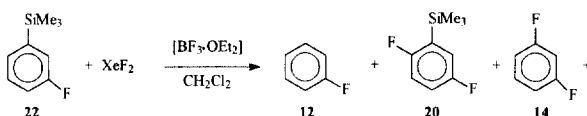
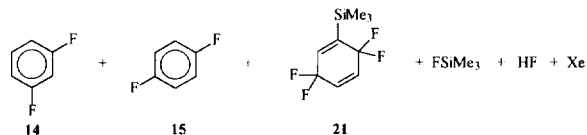
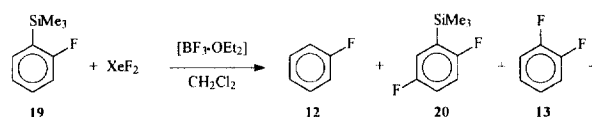
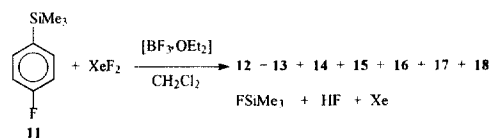


These reactions proceeded easily at room temperature and were complete within 15–20 min. No changes of products were observed during the next 1–2 days in reaction mixtures which contain a slight excess of XeF_2 . This demonstrates the stability of silyldienes **2**, **4**, **5** and **9** towards protodesilylation by HF and fluorodesilylation by XeF_2 and fluorodeprotonation (**2**, **4** and **9**) under the reaction conditions (cf. [2]). For this reason, diene **8** must have been produced from pentafluorobenzene which was the product of fluorodesilylation of **3** and **10**.

These results show a close similarity with those obtained earlier with tetrafluorobenzenes $\text{C}_6\text{HF}_4\text{R}$ [2]. The only difference is the partial replacement of the trimethylsilyl group by the fluorine atom in the case of silylbenzenes **3** and **10** while the trimethylsilyl group *para* to hydrogen (silylbenzene **1**) remained unaffected. This demonstrates the influence of the mutual disposition of aromatically bonded fluorine atoms and SiMe_3 group on the character of the reaction products. From this viewpoint it was also interesting to investigate the interaction of isomeric trimethylsilylfluorobenzenes with XeF_2 in the presence of Lewis acid. It should be noted that Lothian and Ramsden [3] have reported the reaction of 4- $\text{RC}_6\text{H}_4\text{SiMe}_3$ ($\text{R} = \text{H, Cl, MeO, } t\text{-Bu}$) with excess of XeF_2 in hexafluorobenzene in the absence of Lewis acid. They observed the formation of 4- $\text{RC}_6\text{H}_4\text{F}$ (major), isomers of 4- $\text{RC}_6\text{H}_3\text{FSiMe}_3$ and 4- $\text{RC}_6\text{H}_3\text{F}_2$ (minor) and offered this method for the regiospecific fluorodesilylation of silylbenzenes like the well known regiospecific functionalisation of mono- and di-substituted trimethylsilylbenzenes via desilylation by the action of electrophilic reagents [4].

We have found that the reaction of trimethylsilylfluorobenzenes with XeF_2 under acidic catalysis proceeds in a more complex way. Trimethylsilyl-4-fluorobenzene **11** reacted with a slight excess of xenon difluoride and a catalytic amount of $\text{BF}_3 \cdot \text{OEt}_2$ in CH_2Cl_2 to give fluorobenzene **12**, 1,2-difluorobenzene **13**, 1,3-difluorobenzene **14**, 1,4-difluorobenzene **15**, 1,2,4-trifluorobenzene **16**, 1-trimethylsilyl-3,4-difluoro-

benzene **17** and 3,3,6,6-tetrafluoro-1,4-cyclohexadiene **18**. Similar reactions took place with the other isomeric trimethylsilylfluorobenzenes. Treatment of 1-trimethylsilyl-2-fluorobenzene **19** with xenon difluoride in the presence of $\text{BF}_3 \cdot \text{OEt}_2$ gave fluorobenzene **12**, difluorobenzenes **13**–**15**, 1-trimethylsilyl-2,5-difluorobenzene **20** and 1-trimethylsilyl-3,3,6,6-tetrafluoro-1,4-cyclohexadiene **21**. Compounds **12**–**18**, **20** were obtained by the reaction of XeF_2 with 1-trimethylsilyl-3-fluorobenzene **22**. In all cases fluorotrimethylsilane, HF and traces of CH_2FCl were detected among the reaction products while the initial amount of xenon difluoride was totally consumed. The reactions of **11**, **19** and **22** were accompanied by the formation of tar as for the fluorination of mono-substituted benzenes $\text{C}_6\text{H}_5\text{R}$ [5] but the formation of fluorinated biphenyls was not found by ^{19}F NMR spectrometry or GC-MS.



Obviously, for silylbenzenes $\text{C}_6\text{FH}_4\text{SiMe}_3$ no regioselectivity was found for the fluorodesilylation reactions. The complex composition of the reaction mixtures arises from further interactions of the primary aromatic products with

(CH₂Cl₂), δ : -100.4 (F-6), -120.3 (F-2), -130.1 (F-4), -166.5 (F-3) ppm (cf. Ref. [21]).

3.2. Reactions of xenon difluoride with trimethylsilyltetrafluorobenzenes

3.2.1. 1-Trimethylsilyl-2,3,5,6-tetrafluorobenzene **1**

Xenon difluoride (100 mg, 0.59 mmol) was added in portions to the solution of silylbenzene **1** (101 mg, 0.45 mmol) and BF₃·OEt₂ (ca. 15 mg) in dichloromethane (0.2 ml) at 0°C. After each addition the reaction mixture was warmed to room temperature until gas evolution was ceased. The ¹H and ¹⁹F NMR spectra showed the presence of silyldiene **2** (yield 89%), traces of CH₂FCl and BF₃·OEt₂. That solution was washed with water, diluted with MeCN (0.3 ml) and treated with excess of KF·2 H₂O. After 24 h, the organic phase was separated from the solid residue and analysed by ¹H and ¹⁹F NMR spectrometry. Hexafluorocyclohexadienes **23** and **26** were obtained in 62 and 18% yields, respectively, together with FSiMe₃ and (Me₃Si)₂O.

3.2.2. 1-Trimethylsilyl-2,3,4,6-tetrafluorobenzene **3**

Similarly, silyldienes **4** (55%), **5** (10%), diene **8** (4%), silane **6** (4%) and pentafluorobenzene **7** (15%) were obtained from silylbenzene **3** (162 mg, 0.73 mmol), BF₃·OEt₂ and XeF₂ (156 mg, 0.92 mmol) in dichloromethane (0.2 ml) together with HF and FSiMe₃ (¹H, ¹⁹F NMR). Treatment of the reaction mixture with KF·2 H₂O (excess) and MeCN overnight led to the conversion of silanes **4**, **5** and **6** into the known compounds **24**, **8** and **7**.

3.2.3. 1-Trimethylsilyl-2,3,4,5-tetrafluorobenzene **10**

In a similar way, silylbenzene **10** (82 mg, 0.37 mmol), XeF₂ (84 mg, 0.49 mmol), BF₃·OEt₂ (ca. 20 mg) in CH₂Cl₂ (0.2 ml) gave compounds **9** (57%), **8** (5%), **5** (19%), **6** (2%) and **7** (2%) besides HF and FSiMe₃. Washing with water following treatment with excess of KF·2 H₂O in CH₂Cl₂-MeCN overnight led to the conversion of **9**, **5** and **6** into dienes **25**, **8** and pentafluorobenzene, respectively (¹H, ¹⁹F NMR).

3.3. Reactions of xenon difluoride with trimethylsilylfluorobenzenes

3.3.1. 1-Trimethylsilyl-2-fluorobenzene **19**

Reaction of silylbenzene **19** (110 mg, 0.65 mmol) with XeF₂ (115 mg, 0.68 mmol) in CH₂Cl₂ (0.2 ml) in the presence of BF₃·OEt₂ was performed as above and was complete within 10–15 min. Silylbenzene **20** (30%), fluorobenzene **12** (16%), difluorobenzenes **13** (3%), **14** (4%), **15** (5%) and

diene **21** (5%) plus FSiMe₃, HF and traces of CH₂FCl were identified by ¹H and ¹⁹F NMR spectrometry.

3.3.2. 1-Trimethylsilyl-3-fluorobenzene **22**

Compounds **12** (6%), **13** (4%), **14** (10%), **15** (16%), **16** (3%), **18** (3%), **20** (17%) and **21** (4%) were obtained from silylbenzene **22** (125 mg, 0.74 mmol) and XeF₂ (154 mg, 0.91 mmol) in CH₂Cl₂ (0.2 ml) in the presence of BF₃·OEt₂. Additionally traces of silylbenzene **17** plus fluorotrimethylsilane, HF and CH₂FCl were detected (¹H, ¹⁹F NMR).

3.3.3. 1-Trimethylsilyl-4-fluorobenzene **11**

Silylbenzene **11** (80 mg, 0.47 mmol) was treated with XeF₂ (105 mg, 0.62 mmol) in CH₂Cl₂ (0.2 ml) in the presence of ca. 15 mg of BF₃·OEt₂ and formed compounds **12** (13%), **13** (3%), **14** (4%), **15** (34%), **16** (4%), **17** (3%) and **18** (5%) together with HF and FSiMe₃ (¹H, ¹⁹F NMR).

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